

Supplementary Information (SI)

High selectivity for n-dodecane hydroisomerization over highly siliceous ZSM-22
with low Pt loading

Pengyu Niu^{a,b}, Hongjuan Xi^a, Jun Ren^c, Minggui Lin^a, Qiang Wang^a, Litao Jia^a, Bo
Hou^{a,*}, and Debao Li^{a,*}

^a State Key Laboratory of Coal Conversion, Institute of Coal Chemistry, Chinese
Academy of Sciences, Taiyuan 030001, People's Republic of China

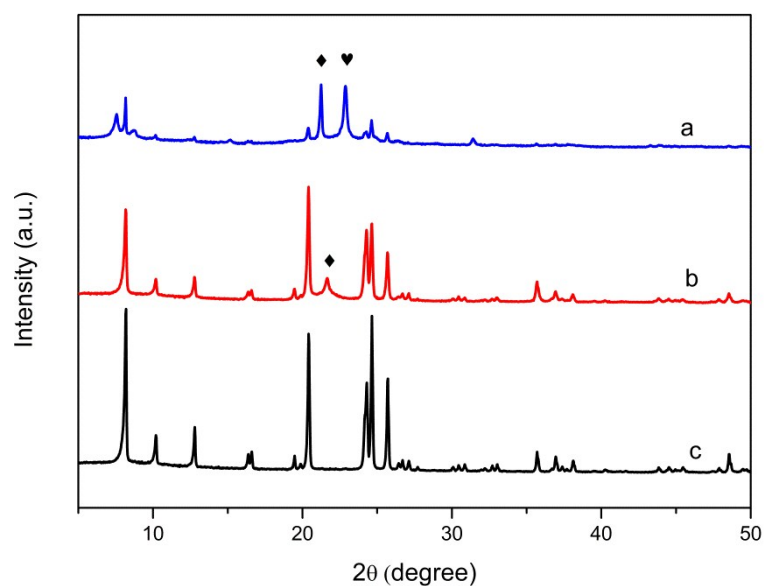
^b University of Chinese Academy of Sciences, Beijing 100049, People's Republic of
China

^c School of Chemical and Environmental Engineering, North University of China,
Xueyuan Road 3, Taiyuan, 030051, China

* Corresponding Author

E-mail: houbo@sxicc.ac.cn.

dbli@sxicc.ac.cn.



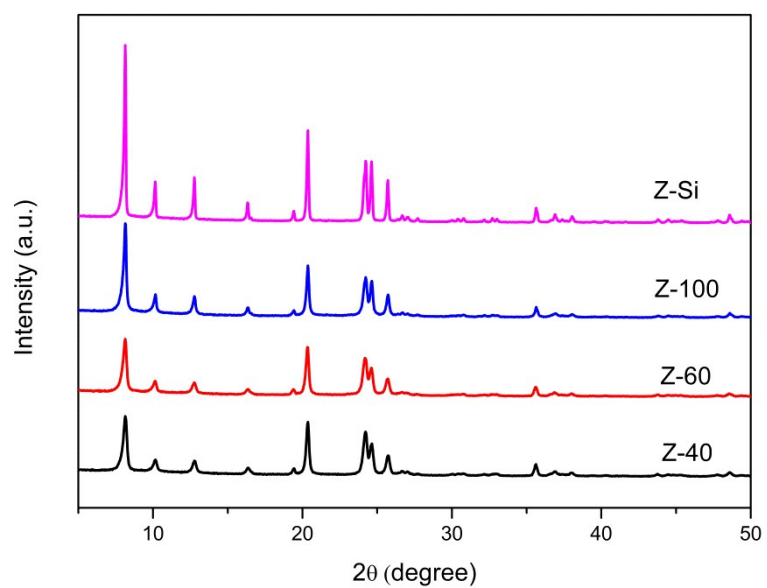
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24 Figure S1. XRD patterns of samples obtained under different crystallization
 25 conditions. (a) crystallization without seeds at 160 °C, (b) crystallization with seeds at
 26 160 °C, and (c) crystallization with seeds at 150 °C.

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28 Figure S2 shows the XRD patterns of Z-40, Z-60, Z-100 and Z-Si. The relative
 29 intensity of diffraction peaks was enhanced with increasing of the Si/Al ratio. Strong
 30 peak at 24.65° was observed upon increasing of the Si/Al ratio, which became much
 31 stronger in siliceous ZSM-22. The differences are mainly caused by the difference in
 32 crystal growth where aluminum plays a significant role in the formation of ZSM-22
 33 crystal¹.

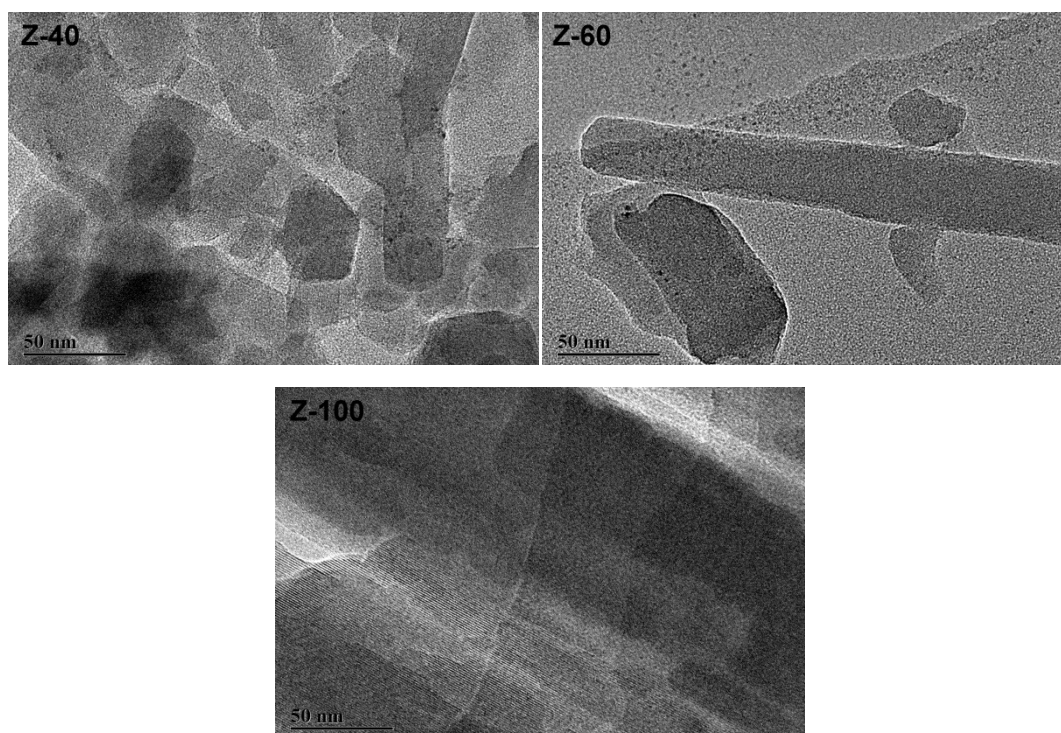
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36 Figure S2. XRD patterns of Z-40, Z-60, Z-100 and Z-Si.

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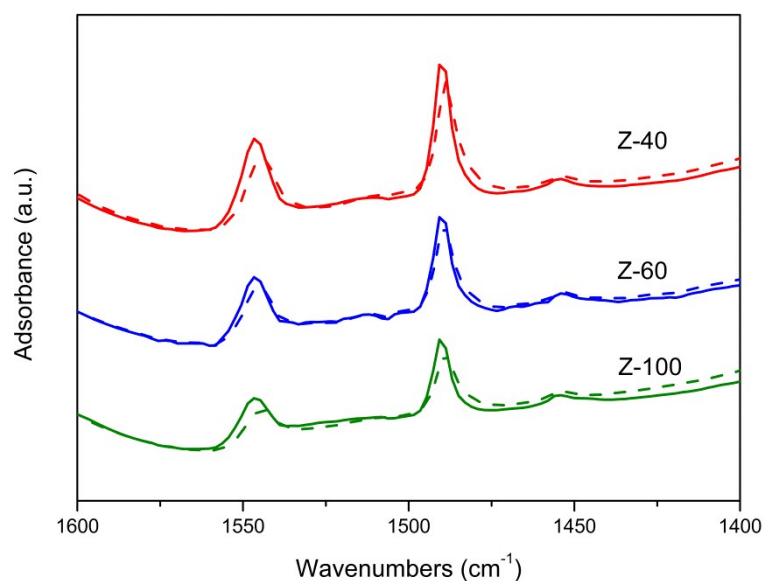
40 Figure S3. TEM images of Z-40, Z-60, and Z-100.

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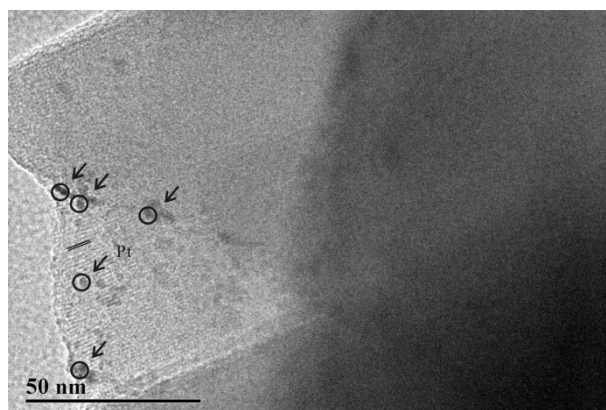
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46 Figure S4. IR spectra of pyridine adsorbed on different samples at 200 °C (solid line)
47 and 350 °C (dash line)

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50 Figure S5. TEM image of Pt/Z-Si.

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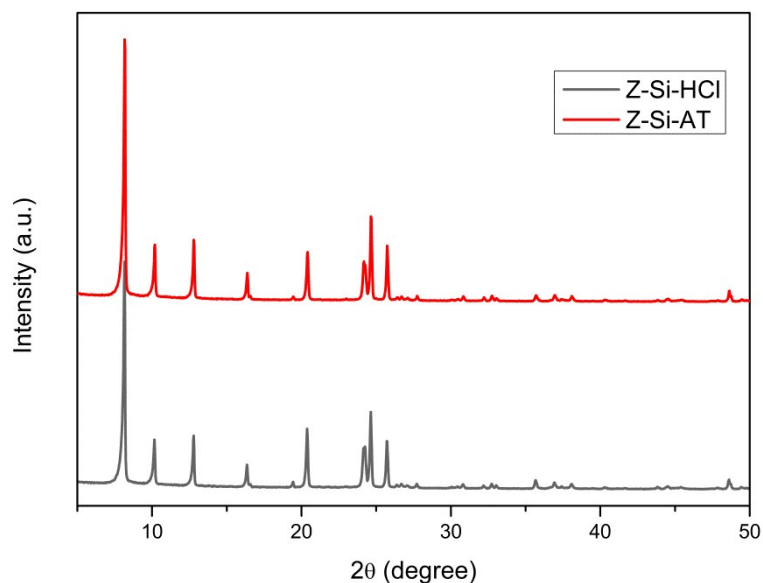
52 After HCl and alkaline solution treatment, the relative crystallinity and the textural
53 properties of the two samples did not change obviously, shown in Figure S6 and S7.

54 The textural properties of Z-Si, Z-Si-HCl and Z-Si-AT are listed in Table S1.

55 Both of Z-Si-HCl and Z-Si-AT were observed a weak signal centered at around -

56 103 ppm assigned to Q^3 environment, indicating the presence of defective sites. The
 57 presence of defective sites was also confirmed by $^1H^{29}Si$ CPMAS NMR spectrum of
 58 the two samples shown in Figure S8 (b). Structural defects ($HO-Si-[(OSi)_3]$) and
 59 ($[HO]_2-Si-[(OSi)_2]$) can be detected after alkaline solution treatment.

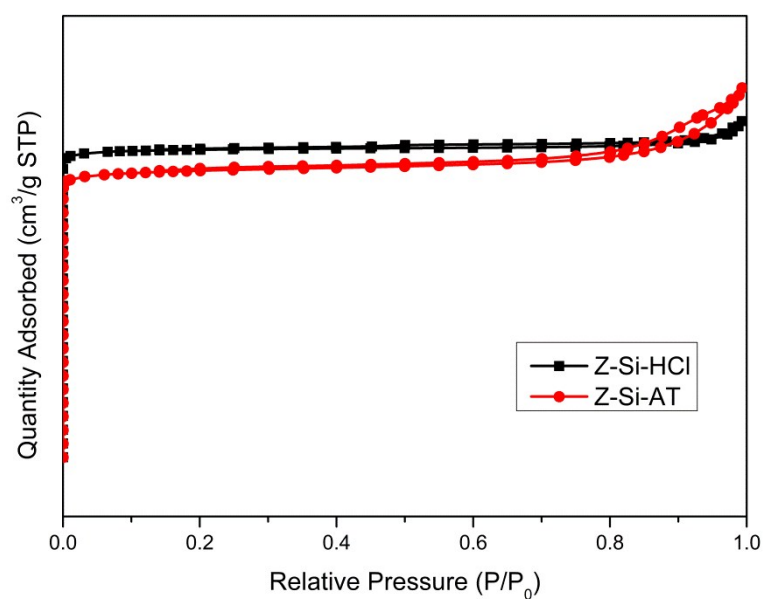
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62 Figure S6. XRD patterns of Z-Si-HCl and Z-Si-AT.

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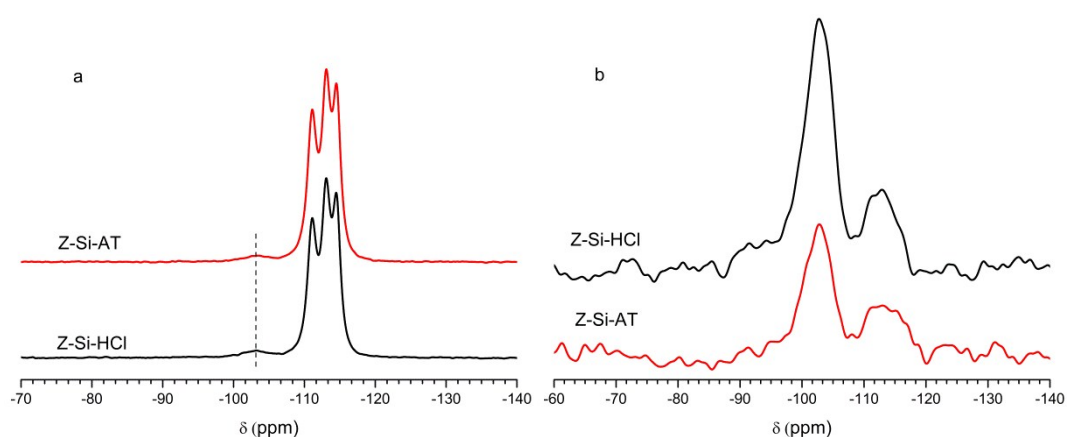
65 Figure S7. N_2 adsorption isotherms of Z-Si-HCl and Z-Si-AT.

66 Table S1. Textural characterization of Z-Si, Z-Si-HCl and Z-Si-AT

Samples	Si/Al ^a	S _{BET} (m ² g ⁻¹)	S _{micro} (m ² g ⁻¹)	S _{ext} (m ² g ⁻¹)	V _{micro} (cm ³ g ⁻¹)	Brønsted acid (μmol g ⁻¹)
Z-Si	990	279	266	13	0.10	13
Z-Si-HCl	1344	293	287	6	0.10	7
Z-Si-AT	950	275	263	12	0.10	5

67 ^a Determined by ICP-OES.

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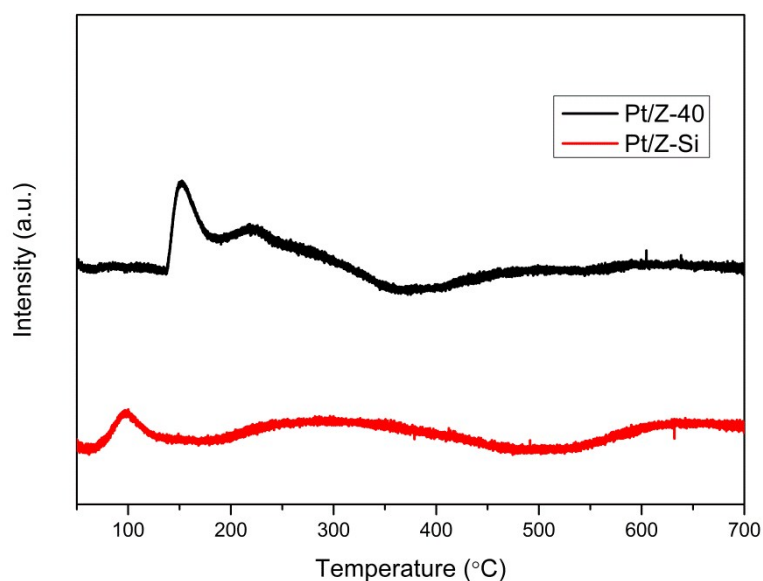
70 Figure S8. (a) ²⁹Si MAS NMR spectra and (b) ¹H²⁹Si CPMAS NMR spectrum of Z-
71 Si-HCl and Z-Si-AT.

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73 Table S2. CO chemisorption of Pt/Z-40 and Pt/Z-Si.

Catalysts	Pt dispersion (%)	Pt particle diameter (nm)
Pt/Z-40	53.57	2.11
Pt/Z-Si	20.51	5.52

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76 Figure S9. H₂ TPR spectra of the different samples.

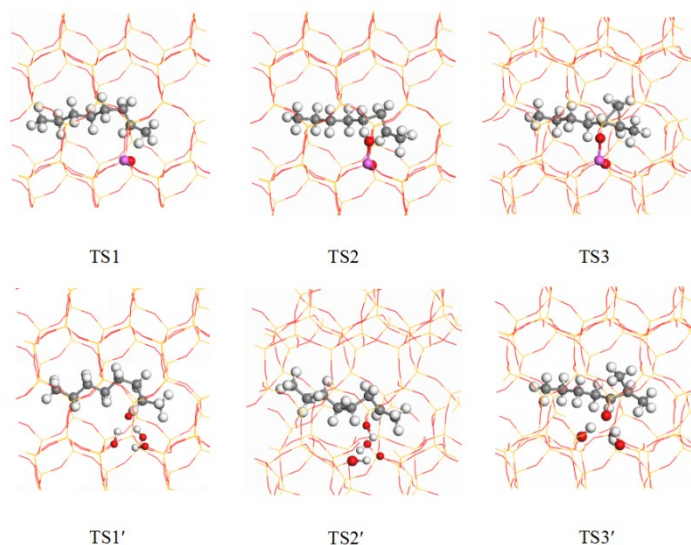
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78 The detailed mechanism for how linear alkenes are transformed into branched
 79 alkenes over acidic zeolites has also been extensively investigated by theoretical
 80 chemistry methods, which conclude that linear alkoxide intermediates formed upon
 81 adsorption are more stable than physisorbed linear alkenes. Moreover, the
 82 isomerization of a linear alkoxide into a branched alkoxide occurs via a protonated
 83 cyclopropane species as a transition state which is energetically favored compared to
 84 directly shifting the alkyl group.^{2, 3} The mechanism for 1-octene hydroisomerization
 85 involves (i) 1-octene adsorption on the zeolite acid site to form physisorbed π -
 86 complex, (ii) and then to form a linear alkoxide species, (iii) isomerization of this
 87 linear alkoxide species into a branched alkoxide species, (iv) desorption of the
 88 branched alkoxide to form a mono-branched alkene and concurrent regeneration of
 89 the zeolitic acid site.

90 The basic steps for this mechanism have already been briefly outlined (see Figure 13).

91 The starting structure is a physisorbed π -complex, and then a linear alkoxide is
92 formed via one step hydrogenation with a lower energy barrier 46.3 and 84.9 kJ/mol
93 on silica-alumina and siliceous ZSM-22, respectively. This obtained a protonized
94 molecule representing the first transition state (TS 1), shown in Figure S3. The next
95 step starts from adsorbed alkoxide and forms an important configuration along the
96 reaction energy path corresponds to a stable charged cyclopropane intermediate (see
97 Figure S10), and this energy barrier is 78.2 and 137.0 kJ/mol on silica-alumina and
98 siliceous ZSM-22, respectively. For the ring opening via the deprotonation of the
99 cyclopropane configuration, the activation energy of 47.3 kJ/mol for silica-alumina
100 ZSM-22 is obtained, which is lower than that of siliceous ZSM-22 with activation
101 energy of 79.1 kJ/mol. The final reaction step is that the proton is transferred back to
102 the acid site and binds to the C3 carbon atom, and C3-C4 carbon bond is broken to
103 form branched alkoxide. The complete reaction pathway is depicted in Figure 13. The
104 overall reaction, beginning from a physisorbed π -complex to a branched one, involves
105 in total three transition states and two intermediates. The imaginary frequency of all
106 transition states is listed in Table S3.

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109 Figure S10. Transition state geometries (TS1-3 and TS1'-3') for catalytic
110 isomerization of 1-octene in silica-alumina and siliceous ZSM-22, respectively.

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112 Table S3. The imaginary frequency of all transition states.

Transition state	imaginary frequency
TS1	212 <i>i</i>
TS1'	189 <i>i</i>
TS2	180 <i>i</i>
TS2'	175 <i>i</i>
TS3	162 <i>i</i>
TS3'	207 <i>i</i>

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114 **References**

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